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# How carbon contamination on the photocatalysts interferes with the performance analysis of CO<sub>2</sub> reduction†

Jiakang You,<sup>a</sup> Mu Xiao,<sup>a</sup> Siqi Liu, <sup>b</sup> Haijiao Lu,<sup>a</sup> Peng Chen, <sup>b</sup> Zhi Jiang, <sup>b</sup> Wenfeng Shangguan,<sup>b</sup> Zhiliang Wang <sup>a</sup> and Lianzhou Wang <sup>b</sup> \*

Photocatalytic carbon dioxide (CO<sub>2</sub>) reduction reaction (CO<sub>2</sub>RR) for the production of valuable chemicals is a promising solar-driven strategy to mitigate CO<sub>2</sub> emissions. However, carbon contamination on the photocatalysts interferes with the investigation of CO2RR performance. This work quantitatively investigates the significant impact of carbon contamination on performance analysis of photocatalytic CO<sub>2</sub>RR, which can lead to false-positive results of photocatalysts with different types of band structure (i.e., TiO2, CuO, and BiVO<sub>4</sub>) due to photoinduced oxidation process. Moreover, the commonly used organic solvent in a laboratory environment (e.g., ethanol) was proved to have a profound impact on photocatalytic CO<sub>2</sub>RR behaviour wherein 1 microliter of ethanol could boost the apparent methane generation by 17 times. To solve this issue, oxygen plasma treatment is demonstrated to be effective in removing surface carbon contamination. To minimise the impact of surface carbon contamination and eliminate false-positive results, it is expected to further enhance the photocatalytic performance and store catalysts in a carbon-free atmosphere.

The rapid consumption of fossil fuels in human activities, such as transport, industry, and household sectors, causes a striking increase in CO<sub>2</sub> concentration in the atmosphere, leading to serious environmental issues, such as global warming and ocean acidification.<sup>1,2</sup> Thus, these problems must urgently be addressed by reducing CO<sub>2</sub> emissions and making full utilisation of the existing CO<sub>2</sub>. Photocatalytic CO<sub>2</sub> reduction reaction (CO<sub>2</sub>RR) has attracted global research interest over the past decades.<sup>3</sup> In an ideal process, it is expected that the photogenerated electrons in the photocatalysts are applied to reduce

Despite tremendous research efforts, the production rates of carbon monoxide (CO) and methane (CH<sub>4</sub>), which are the most common products, stay at low levels (e.g., <17.33 μmol g<sup>-1</sup> h<sup>-1</sup> for CO and <2000 μmol g<sup>-1</sup> h<sup>-1</sup> for CH<sub>4</sub>).<sup>5-12</sup> However, external factors, such as organic vapours in a lab, surface carbon contamination, etc., are more likely to produce these carbon products via oxidation reaction, other than CO<sub>2</sub> reduction, and therefore they might result in false-positive signals. For example, methanol (CH3OH), a common hole scavenger in photocatalytic reactions, can produce significant amounts of CO through a photocatalytic oxidation process. 13-16 Although isotope analysis is regarded as an effective approach to verify the carbon source by tracing the 13C transfer from CO2 molecules to the products, the possible isotopic substitution makes this method less reliable.17-20 To provide reproducible and convincing data for CO<sub>2</sub>RR analysis, some recent perspectives invoked the elimination of contamination sources as completely as possible.21,22 Yet, there is still no quantitative investigation on how carbon contamination interferes with the performance analysis of photocatalytic CO<sub>2</sub>RR.

In this work, we have provided a quantitative analysis of the apparently over-estimated product amount due to hole-induced contamination oxidation, other than the  $\rm CO_2RR$  process. Photocatalysts with different valence band (VB) positions have been applied to verify that the contamination oxidation reaction exaggerates the apparent  $\rm CO_2RR$  activity. Using a prototypical Au/TiO<sub>2</sub> photocatalyst for  $\rm CO_2RR$ , introducing a trace amount (i.e., 1  $\mu$ L) of ethanol (EtOH) caused over 17 times higher  $\rm CH_4$  production rate and higher stability for CO production. Moreover, facile oxygen plasma pre-treatment was confirmed to be an effective protocol to minimise the influence of carbon contamination during gas-phase photocatalytic  $\rm CO_2$  conversion. These findings provide new insights into  $\rm CO_2RR$  research

 $CO_2$ , meanwhile, photogenerated holes are consumed for water oxidation. Considering the stable structure of  $CO_2$  with a high bond energy of 750 kJ mol<sup>-1</sup>,<sup>4</sup> there is a high energy barrier for the activation of  $CO_2$ , which requires sophisticated photocatalyst designs.

<sup>&</sup>lt;sup>a</sup>Nanomaterials Centre, School of Chemical Engineering and Australian Institute for Bioengineering and Nanotechnology, The University of Queensland, St Lucia, Queensland, 4072, Australia

<sup>&</sup>lt;sup>b</sup>Research Center for Combustion and Environment Technology, Shanghai Jiao Tong University, Shanghai, 200240, China. E-mail: zhiliang.wang@uq.edu.au; l.wang@ uq.edu.au

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and will enable the acquisition of more consistent and reliable quantitative results across the research community.

The Au/TiO2 has been intensively investigated to be an effective photocatalyst for CO2RR, which makes it a good benchmark for investigating the carbon contamination issue. The prototypical Au/TiO<sub>2</sub> photocatalysts have been widely reported to be active towards gas-phase CO2 conversion to CO and CH<sub>4</sub>, with a production rate ranging from 3 to 210  $\mu$ mol g<sup>-1</sup> h<sup>-1</sup> depending on reaction conditions.<sup>5,23</sup> Considering the ultralow dosage of photocatalyst (c.a. 10 mg) in the reported research, the absolute yields of CO2RR products are negligible. In our research, we adopted a similar procedure to coat the asprepared Au/TiO2 photocatalyst (ESI†) on a glass substrate with a rough surface. Herein, Au was deposited via chemical reduction by sodium borohydride to avoid introducing organic sources on the TiO2 surface.24-26 The X-ray diffraction (XRD) (Fig. S1†) and transmission electronic microscopy (TEM) (Fig. S2†) of the as-produced Au/TiO2 indicate that the Au nanoparticles were deposited on the TiO2 surface.

Photocatalytic CO2 conversion was carried out in a batch reactor, wherein the system was filled with pure CO<sub>2</sub> (>99.9%) before turning on the lighting (ESI†). Fig. 1a and b show the CO and CH<sub>4</sub> with a mass-specific production (MSP) of 30 μmol g<sup>-1</sup> and 67.5 µmol g<sup>-1</sup>, respectively, in 90 minutes. This photocatalytic activity is comparable to literature results based on similar Au/TiO2 systems.27-31 Unexpectedly, in the controlled experiment, where the photocatalytic system was filled with argon gas (Ar), obvious CH4 and CO production was also detected. Especially, the absolute yields of CH4 were very close to the case in the presence of CO<sub>2</sub>, indicating that the apparent CO<sub>2</sub>RR activity has been overestimated as shown in Fig. 1b. In addition, profound H2 production (Fig. S3†) was observed in both cases (while no oxygen was detected), which may lead to a noticeable CO decrease as shown in Fig. 1a via hydrogenation. With the above results, there is a question on the origin of CO and CH<sub>4</sub> under an Ar atmosphere.

X-ray photoelectron spectroscopy (XPS) was used to determine the surface chemical environment of  $TiO_2$  (Fig. 1c). Although we avoided the organic sources during photocatalyst preparation, the carbon peak could always be observed even on the pure inorganic metallic samples, which is indexed to ubiquitous carbon contamination from air exposure.<sup>32</sup> This peak is commonly used as a reference value to calibrate XPS

data, representing C–C or C–H bond. $^{32-34}$  These carbon species can produce extra CO or  $\mathrm{CH_4}$  with the interaction with the photogenerated charges.

The applied TiO<sub>2</sub> holds a large bandgap, where it is capable of producing CO and CH<sub>4</sub> either by CO<sub>2</sub> reduction reaction or via carbon contamination oxidation. To get more insight into whether photogenerated electrons or holes contribute more to the CO and CH<sub>4</sub> generation, the other two semiconductors, BiVO<sub>4</sub> and CuO, were selected due to their band structure features (Fig. 2a, see ESI† for details on preparation). Ultraviolet photoelectron spectroscopy (UPS) and ultraviolet-visible (UVvis) spectroscopy were used to further determine the band positions as shown in Fig. S4 and S5.† The properties of the valence band (VB) and conduction band (CB) of BVO4, CuO, and TiO<sub>2</sub> are summarised in Fig. 2a, which shows the CB of CuO and VB of BiVO<sub>4</sub> to be close to the CB and VB of TiO<sub>2</sub>, respectively, in accordance with the literature. 35-37 From the relative position of CB (-3.73 eV) to the redox potential of CO<sub>2</sub>/CO (-4.38 eV) and  $CO_2/CH_4$  (-4.67 eV), it can be concluded that only CuO can facilitate the CO<sub>2</sub>RR. While the relatively shallow VB (-5.05 eV)of CuO makes it unlikely to process contamination oxidation. The BiVO<sub>4</sub> has the opposite situation in that CO<sub>2</sub>RR is unlikely to happen due to the thermodynamic limit of CB (-5.03 eV), but the contamination oxidation process is relatively easy due to the deep VB (-7.43 eV). Therefore, the photocatalytic performance of CuO and BiVO<sub>4</sub> can help distinguish whether the CO<sub>2</sub>RR or oxidation of carbon contaminations contributes to the apparent CO and CH<sub>4</sub> generation. Surface carbon content on the TiO<sub>2</sub>, CuO, and BiVO<sub>4</sub> was determined to be 14.96, 26.02, and 8.44 wt%, respectively, as analysed by XPS (Table S1†).

Their photocatalytic performance is shown in Fig. 2b and c and S7.† Interestingly, BiVO<sub>4</sub> produced significant amounts of CH<sub>4</sub> (5.4  $\mu$ mol g $^{-1}$ ) and CO (13.5  $\mu$ mol g $^{-1}$ ), while CuO produced nearly null. As mentioned above, products from BiVO<sub>4</sub> indicate that carbon contamination oxidation occurs, which can lead to false-positive CO<sub>2</sub>RR results, despite the consensus that BiVO<sub>4</sub> is not capable of this process. Another photocatalyst, SnO<sub>2</sub>, also possesses a low CB which is challenged for CO<sub>2</sub>RR. <sup>38</sup> However, a considerable amount of CH<sub>4</sub> (3.8  $\mu$ mol g $^{-1}$ ) and CO (13.1  $\mu$ mol g $^{-1}$ ) is observed upon light irradiation (Fig. S8†). We suppose this is also a false-positive result for CO<sub>2</sub>RR caused by carbon contamination oxidation. The absence of a product from CuO

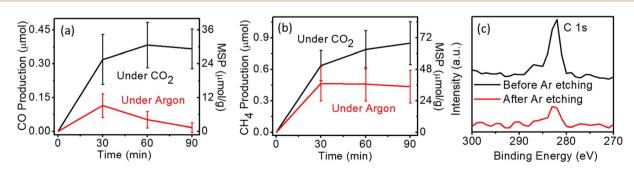


Fig. 1 (a) CO production and (b)  $CH_4$  production from photocatalytic reactions on  $Au/TiO_2$  in  $CO_2$  (black line) or Ar (red line). (c) Comparison of C 1s XPS spectrum of the same  $TiO_2$  sample before and after Ar etching. MSP: mass-specific production.

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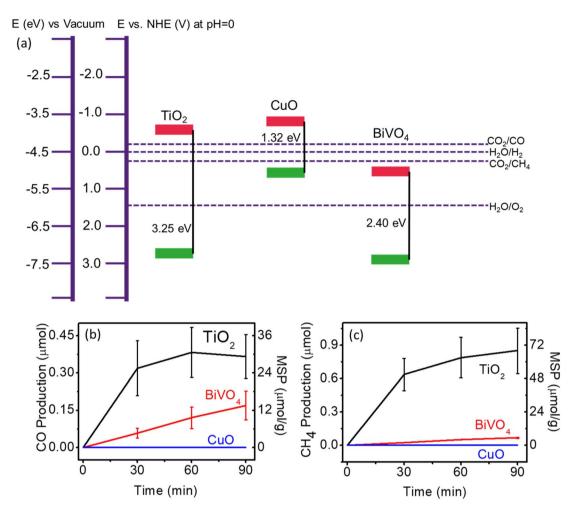


Fig. 2 (a) Band position of TiO<sub>2</sub>, CuO, and BiVO<sub>4</sub> in line with CO<sub>2</sub>RR, redox potentials of hydrogen and oxygen evolution reactions. Photocatalytic CO<sub>2</sub>RR performance over TiO<sub>2</sub>, CuO, and BiVO<sub>4</sub> (b) CO production; (c) CH<sub>4</sub> production. MSP: mass-specific production.

further indicates the significance of the oxidation process for the apparent CO and CH<sub>4</sub> generation.

Carbon-containing photocatalysts have been extensively researched for CO2RR because of their attractive physicochemical properties. Graphitic carbon nitride (g-C<sub>3</sub>N<sub>4</sub>) is one of the most investigated metal-free organic photocatalysts due to its low cost, visible light harvesting, and suitable band position

for CO<sub>2</sub>RR.<sup>39</sup> However, the carbon in g-C<sub>3</sub>N<sub>4</sub> will interfere with the CO2RR performance analysis. Fig. 3 shows the photocatalytic performance on g-C<sub>3</sub>N<sub>4</sub> under Ar and CO<sub>2</sub> atmospheres. The production rates of CO (47.1  $\mu$ mol g<sup>-1</sup>) and CH<sub>4</sub> (3.5  $\mu$ mol g<sup>-1</sup>) under the Ar atmosphere have very small and even negligible difference, as compared to the rates under the CO<sub>2</sub> atmosphere. These results are consistent with the report of

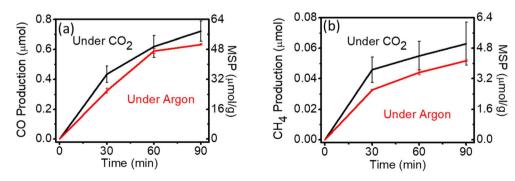


Fig. 3 (a) CO production and (b)  $CH_4$  production from photocatalytic reactions on  $g-C_3N_4$  in  $CO_2$  (black line) or Ar (red line). MSP: mass-specific production.

light-induced self-decomposition of g- $C_3N_4$ , rather than  $CO_2RR.^{40}$  Theoretical calculations have indicated that self-decomposition reaction is thermodynamically more favourable than  $CO_2RR.^{40}$ 

The impact of organic pollution on photocatalytic CO<sub>2</sub>RR is even more pronounced in the presence of ethanol (EtOH), which is a widely used organic solvent for synthesis and a sacrificial agent for photocatalysis. Take the Au/TiO2 system as an example, when 1 µL of EtOH is deliberately added to the reaction system, the CH<sub>4</sub> production rate was boosted by 17 times from 68  $\mu$ mol g<sup>-1</sup> to 1244.8  $\mu$ mol g<sup>-1</sup> as shown in Fig. 4a because of the alcohol and carboxyl acid decomposition under the light.41-45 Meanwhile, a large amount of hydrogen was produced (Fig. S7†), which could inhibit the generation of CO as shown in Fig. 4b. The photocatalytic performance of pure TiO<sub>2</sub> was also evaluated as a reference (Fig. S9†), which showed overall lower activity in the absence of Au cocatalyst. A plausible pathway for EtOH oxidation under light is shown in Fig. 4c. Upon light irradiation, ethanol was oxidised to ethanal with hydrogen generation. Ethanal can be decomposed via three different routes to mislead the photocatalytic CO2RR test. Ethanal can be directly converted to CO<sub>2</sub> and hydrogen via the photocatalytic process. Under ambient conditions, some of the ethanal decomposes to produce CH4 and CO spontaneously.

While, in some cases, the above products would be further oxidised to acetic acid and  $H_2$  with acetic acid being further decomposed to  $CH_4$  and  $CO_2$  upon light illumination. Thus, the introduction of EtOH into the reaction system not only affects the activity analysis, but also influences the selectivity analysis (Table S2†) with considerable hydrogen production (Fig. S7†). Therefore, possible false-positive results can be obtained due to the organic residuals in the system, which must be eliminated when conducting photocatalytic  $CO_2RR$  experiments. Due to the dramatic performance boost by the trace amount of EtOH, researchers in this field should be extremely careful about organic solvent vapours generated in the laboratory environment.

Oxygen plasma treatment is commonly used to eliminate residual organic ligands from the material surface. To avoid the interference of surface contamination, oxygen plasma cleaning was performed to etch the surface of the photocatalyst (i.e., Au/  $\rm TiO_2$ ). Fig. 5 and  $\rm S10^{\dagger}$  show the photocatalytic performance of treated Au/ $\rm TiO_2$  photocatalysts. In the Ar environment, the CO and CH<sub>4</sub> production rates decreased dramatically to a negligible level, especially for CH<sub>4</sub>; the production rate for CH<sub>4</sub> dropped from 34 to 4.69 µmol g<sup>-1</sup>, indicating the effectiveness of the oxygen plasma treatment. Therefore, oxygen plasma treatment can be used to effectively clean the surface of the materials

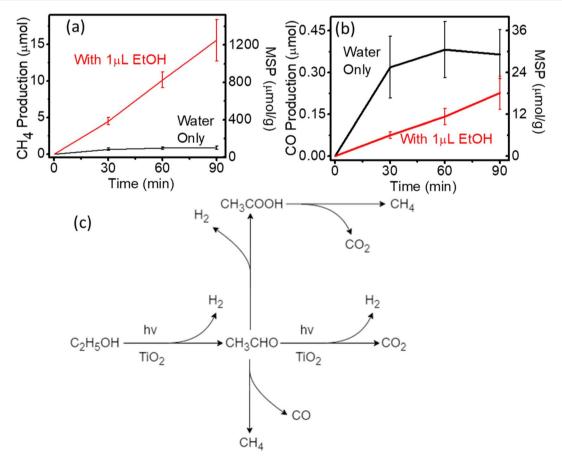


Fig. 4 Photocatalytic performance of  $Au/TiO_2$  with different solvents (a) CO production; (b)  $CH_4$  production. (c) Schematic illustration of photocatalytic ethanol oxidation. MSP: mass-specific production.

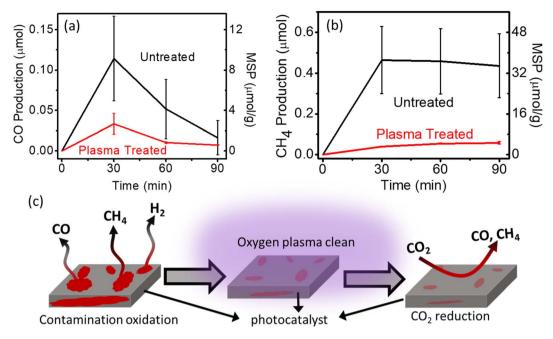


Fig. 5 Controlled experiments before and after plasma treatment under the Ar atmosphere (a) CO production; (b)  $CH_4$  production. MSP: mass-specific production rate. (c) schematic representation of oxygen plasma cleaning.

before conducting photocatalytic experiments as shown in Fig. 5c.

In summary, we have quantitatively shown the influence of carbon contamination on photocatalysts during photocatalytic CO<sub>2</sub>RR activities. When the photocatalytic CO<sub>2</sub>RR activity is low, the impact of the carbon contamination oxidation is therefore significant. The commonly used organic solvent in laboratories (e.g., ethanol) was demonstrated to have a serious impact on photocatalytic CO<sub>2</sub>RR behaviour, leading to false-positive results. To address this issue, oxygen plasma treatment is effective in removing carbon contamination by cleaning the surface of the materials before conducting photocatalytic experiments. The reason for such a significant impact of carbon contamination is the extremely low production rate and carbon conversion rates of photocatalytic CO<sub>2</sub>RR.<sup>46-49</sup> If the production and carbon conversion rates are high enough (e.g., >10 mmol  $g^{-1} h^{-1}$ ), the carbon contamination issue would be negligible. Some strategies can be utilised for higher CO<sub>2</sub>RR performance, such as defect engineering, nanostructure design, cocatalysts design, heterostructure design, and Z-scheme construction. Furthermore, photocatalysts should be stored in a carbon-free environment (e.g., an N2/Ar-filled glove box), if possible, to minimise carbon contamination. Long-term stability tests could decrease the effect of carbon contaminations. Future research should focus on improving the production rate and selectivity and developing highly efficient photocatalysts for CO<sub>2</sub>RR.

### Conflicts of interest

There are no conflicts to declare.

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